

Highly selective optical filtering technology on 300 mm glass wafer for advanced spectroscopy applications

Sandrine Villenave, Stéphane Monfray, Quentin Abadie, Stéphanie Audran, Simon Guillaumet, Delia Ristoiu, H. Benisty

► To cite this version:

Sandrine Villenave, Stéphane Monfray, Quentin Abadie, Stéphanie Audran, Simon Guillaumet, et al.. Highly selective optical filtering technology on 300 mm glass wafer for advanced spectroscopy applications. CLEO: Science and Innovations, May 2022, San Jose, United States. 2022, 10.1364/CLEO_AT.2022.JW3A.41. cea-04828187

HAL Id: cea-04828187 https://cea.hal.science/cea-04828187v1

Submitted on 9 Dec 2024

HAL is a multi-disciplinary open access archive for the deposit and dissemination of scientific research documents, whether they are published or not. The documents may come from teaching and research institutions in France or abroad, or from public or private research centers. L'archive ouverte pluridisciplinaire **HAL**, est destinée au dépôt et à la diffusion de documents scientifiques de niveau recherche, publiés ou non, émanant des établissements d'enseignement et de recherche français ou étrangers, des laboratoires publics ou privés.

Highly Selective Optical Filtering Technology on 300 mm Glass Wafer for Advanced Spectroscopy Applications

S. VILLENAVE*^{†‡}, S. MONFRAY*, Q. ABADIE[‡], S. AUDRAN*, S. GUILLAUMET*, D. RISTOIU*, H. BENISTY[†]

*STMicroelectronics, 38920, Crolles, France

[†]Univ. Paris-Saclay, Institut d'Optique Graduate School, CNRS, Laboratoire Charles Fabry, 91127, Palaiseau, France [‡]Univ. Grenoble Alpes, CEA, LETI, 38000, Grenoble, France Email: {sandrine.villenave1, stephane.monfray, stephanie.audran, simon.guillaumet, delia.ristoiu}@st.com; quentin.abadie@cea.fr; henri.benisty@institutoptique.fr

Abstract: This paper presents the fabrication and measurements of optical rejection filters, made of dielectric nanogratings developed on 300 mm glass wafer using CMOS process. Their suitability for integrated VIS-NIR spectroscopy applications is assessed. © 2022 The Author(s)

1. Introduction

Concerns about environment and health are relentlessly increasing, leading to a demand of sensing resource within everyone's reach. As spectral analysis enables the detection and quantification of numerous chemical species [1], we aim at developing a low-cost technology of multiple parallel optical filters, easy to integrate onto CMOS sensors, and suitable for multispectral applications. An easily fabricated class of filters fit for this purpose are resonant waveguide gratings made of Silicon Nitride (Si₃N₄) embedded in a Silicon Dioxide (SiO₂) matrix, designed on a glass wafer in ST 300 mm platform. Section 2 presents the design and fabrication of these filters, and Section 3 addresses their experimental performances, corroborated by simulation results.

2. Filtering structures

We propose to produce Fano resonances at deterministic wavelengths with periodic 2D gratings, where the primitive cell is square for simplicity. A linear (matrix) relationship then governs the spectrum-signal relations.

2.1. Design

To find the approximate ranges of geometrical parameters such as period, diameter, and pattern height, we use the grating equation (1) which links the effective index n_{eff} of modes propagating in the structure, the incident wave angle and wavelength λ and the main grating parameters, the period, that determines its reciprocal vectors.

$$n_{eff} = n_{inc} \sin(\theta_{inc}) - m \frac{\lambda}{\Lambda}, m \in Z$$
 (1)

Equation (1) [2], directly relates the targeted wavelength λ and the grating period Λ , but more indirectly the pattern's height, that comes through n_{eff}. This latter can be coarsely evaluated by considering the nanostructured layer as uniform thanks to effective-medium theory, and by solving the propagative mode of the multilayer stack at the desired wavelength. Parameters are next refined using optical simulation with RCWA method [3].

2.2. Filter processing

After the design step, filters are processed onto the ST 300 mm platform, see Fig. 1 for individual steps.



Fig. 1. a) 1-Dielectric deposition on Si wafer: Plasma Enhanced Chemical Vapor Deposition (PECVD) of Si₃N₄; 2-Photolithography and etching of cylindrical holes: 3-Filling with SiO₂; 4-Chemical Mechanical Polishing (CMP), direct bonding of glass wafer and grinding; 5-Grinding of Si wafer; b) SEM tilted view and top view of round holes in Si₃N₄ after photolithography and etching; c) TEM cross-section and 3D scheme of the final structure.

We chose to use only SiO₂ and Si₃N₄ because they are adapted to existing CMOS process flow and they do not absorb visible light, enabling good potential performances in the VIS range.

A process set was used to integrate stand-alone filters on glass Fig. 1.a, using steps that can be integrated directly on top of CMOS processed wafers as well. Structures are obtained by photolithography and etching of cylindrical holes into a Si₃N₄ layer Fig 1.b. Holes are filled with SiO₂ that is then planarized to transfer structures on glass wafer by direct bonding. Finally, initial Si substrate is removed Fig. 1.c.

3. Results

Fabricated gratings are measured on a dedicated bench at CEA Leti. Each sample is a 1 mm^2 square, which contains 100 patches of $100x100 \text{ }\mu\text{m}^2$ as seen in Fig. 2.a; each of them is a 2D grating with specific Λ and D. Filtering structures are tested with a microspectrometer, whose source is a white halogen lamp.



Fig. 2. a) Photography in reflection of the one-hundred-filters matrix; b) Transmission measured over 15 selected filters, those highlighted in red on a); c) Transmission of a single filter, measured and simulated with two slightly different spectral pitches.

3.1. Characterization bench

The microspectrometer bench is composed of a microscope, a spectrometer working in UV-VIS-NIR, and a silicon photodetector. The sample, positioned with micrometric precision to target only one filter, is normally illuminated by a white incoherent source with a small but nonzero numerical aperture. Then a collected spot of 20 μ m is analyzed by the spectrometer, with sub-nanometer spectral resolution.

3.2. Measurements

A set of 16 transmission spectra is presented Fig. 2.b, having the following grating parameters: holes depth 70 nm, Si_3N_4 guide thickness 55 nm, period Λ between 220 nm and 520 nm, and diameters D between 120 nm and 460 nm. Their spectral half-widths are 5 to 10 nm, with a dip amplitude -30 % to -44 % over a > 90% baseline.

3.3. Comparison with simulation

Simulations are run with Reticolo [3], a matlab program that implements the RCWA method, well adapted to lowloss periodic structures. As the glass wafer is 210-µm-thick, it is considered as infinite and its interface with air is ignored in simulations, a feature that explains most of the ~3% difference between the measured and simulated background transmission out-of-resonance, Fig. 2.c. Simulations were performed according to feature sizes measured on TEM cross-sections. The agreement is satisfying, with nevertheless an inaccuracy on Λ (or equivalently n_{eff}) that we had to adjust (by a few nanometers) to achieve a perfect match of spectral dip positions. The second lobe, present in many responses such as Fig. 2.b, is well explained by including incident waves from a ~1.25° cone, as done in both simulations Fig. 2.c. This is a plausible impact of the nonzero probe aperture [4]. Then, Fig. 2.c shows the dip depth sensitivity to spectral resolution. Even if the spectrometer precision is subnanometer, the probe aperture prevents achieving the expected resolution and weakens the dip.

4. Conclusion

We have demonstrated experimentally and by simulation a design of filters made with Si₃N₄ and SiO₂ 2D gratings on a 300 mm glass wafer. This technology can achieve numerous narrowly filtered bands, in rejection mode, and enables a rich sampling for integrated spectroscopy applications across visible and near-infrared ranges.

5. References

[1] E.S. McLamore et al., "FEAST of biosensors: Food, environmental and agricultural sensing technologies (FEAST) in North America", Biosensors and Bioelectronics 178 (January 2021).

[2] G. Quaranta et al., "Recent Advances in Resonant Waveguide Gratings", Laser & Photonics Reviews 12, 1800017 (2018).

[3] J.P. Hugonin and P. Lalanne, "Reticolo software for grating analysis", Institut d'Optique, Orsay, France (2005)

http://doi.org/10.5281/zenodo.4419063

[4] L. Devys et al., "Characterization of photonic crystal coupling to and from guided light by absorbance," J. Nanophot. 8(1), 083992 (2014).